



US00D856578S

(12) **United States Design Patent**  
**Pirasteh**

(10) **Patent No.:** **US D856,578 S**

(45) **Date of Patent:** **\*\* Aug. 13, 2019**

- (54) **FOREHEAD MASK**
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- (\*\*) Term: **15 Years**
- (21) Appl. No.: **29/656,538**
- (22) Filed: **Jul. 13, 2018**
- (51) **LOC (12) Cl.** ..... **28-02**
- (52) **U.S. Cl.**  
USPC ..... **D28/7**
- (58) **Field of Classification Search**  
USPC ..... D28/4, 7, 9, 10, 11, 13, 44.2; D20/22;  
D3/247; D29/108-110; D24/189, 206,  
D24/208  
CPC .. B65H 51/22; D03J 33/00; A61F 7/00; A61F  
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See application file for complete search history.

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 Scheef & Stone, L.L.P.

(57) **CLAIM**

The ornamental design for a forehead mask, as shown and described.

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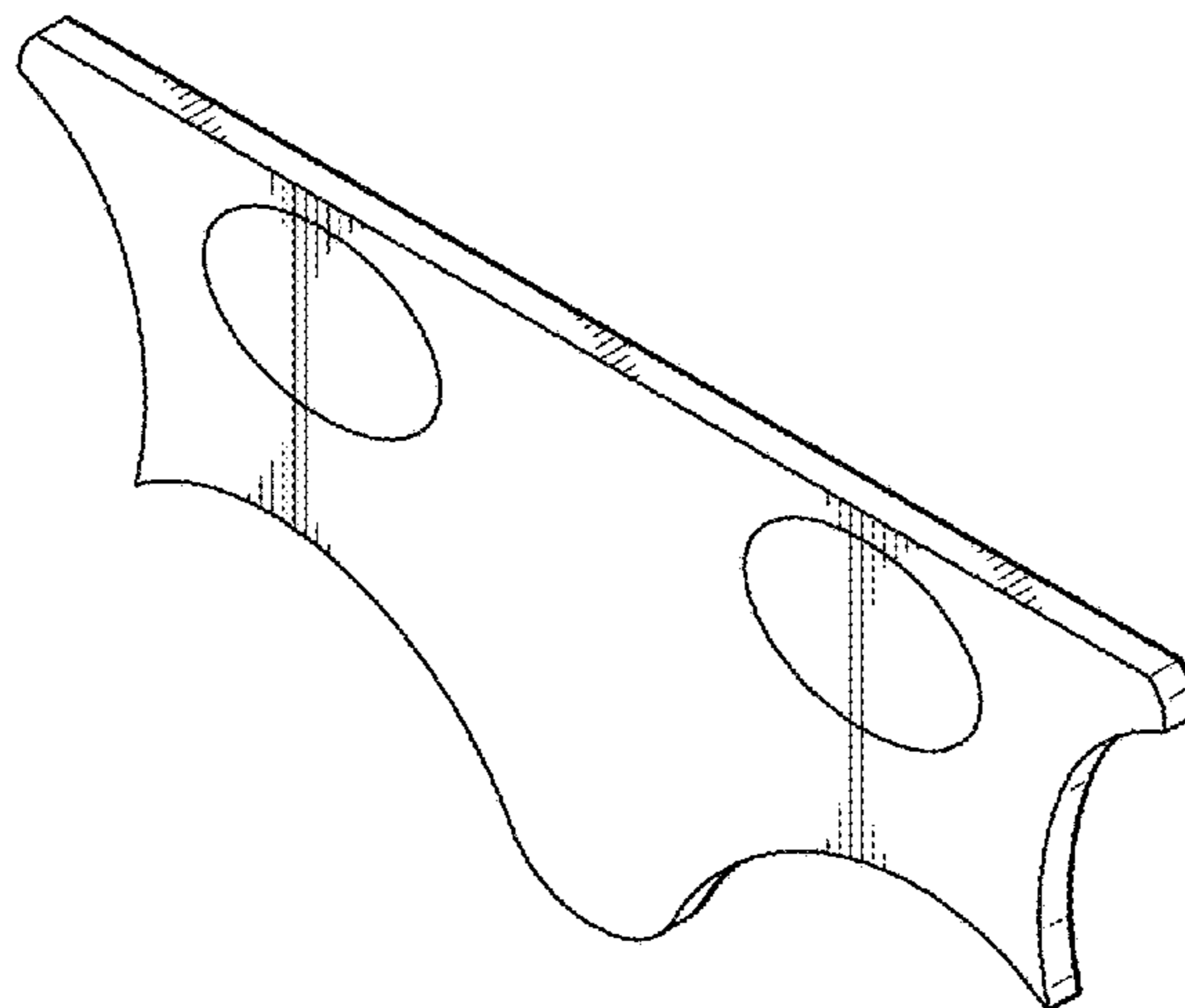
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**DESCRIPTION**

FIG. 1 is a perspective view of a forehead mask;  
 FIG. 2 is a front view thereof;  
 FIG. 3 is a rear view thereof;  
 FIG. 4 is a right view thereof;  
 FIG. 5 is a left view thereof;  
 FIG. 6 is a top view thereof;  
 FIG. 7 is a bottom view thereof;  
 FIG. 8 is an exploded perspective view thereof;  
 FIG. 9 is a perspective view thereof, shown in an environment of use; and,  
 FIG. 10 is a perspective view thereof, shown in another environment of use.  
 In the drawings, the broken lines represent environmental subject matter and form no part of the claimed design.

**1 Claim, 5 Drawing Sheets**



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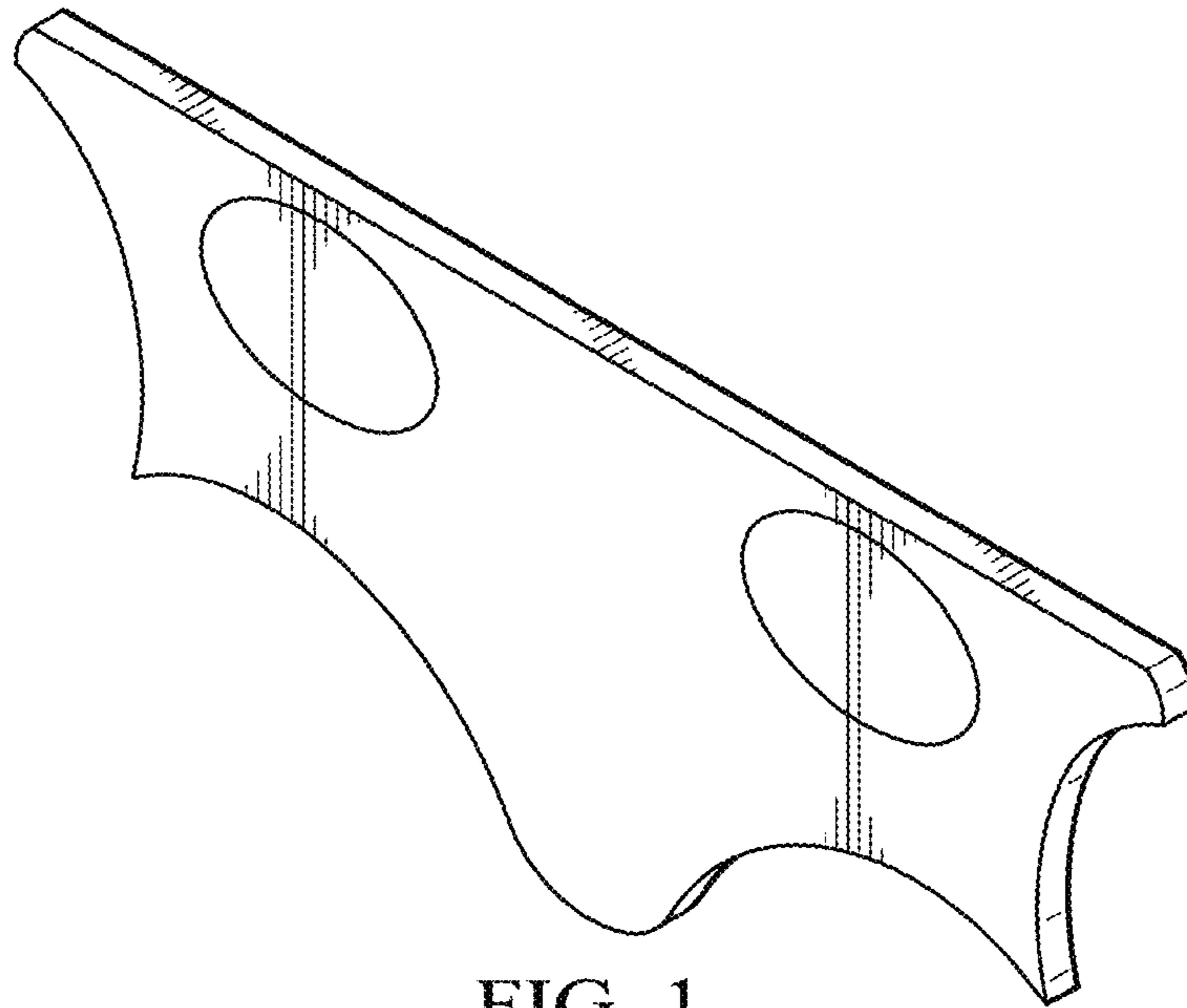


FIG. 1

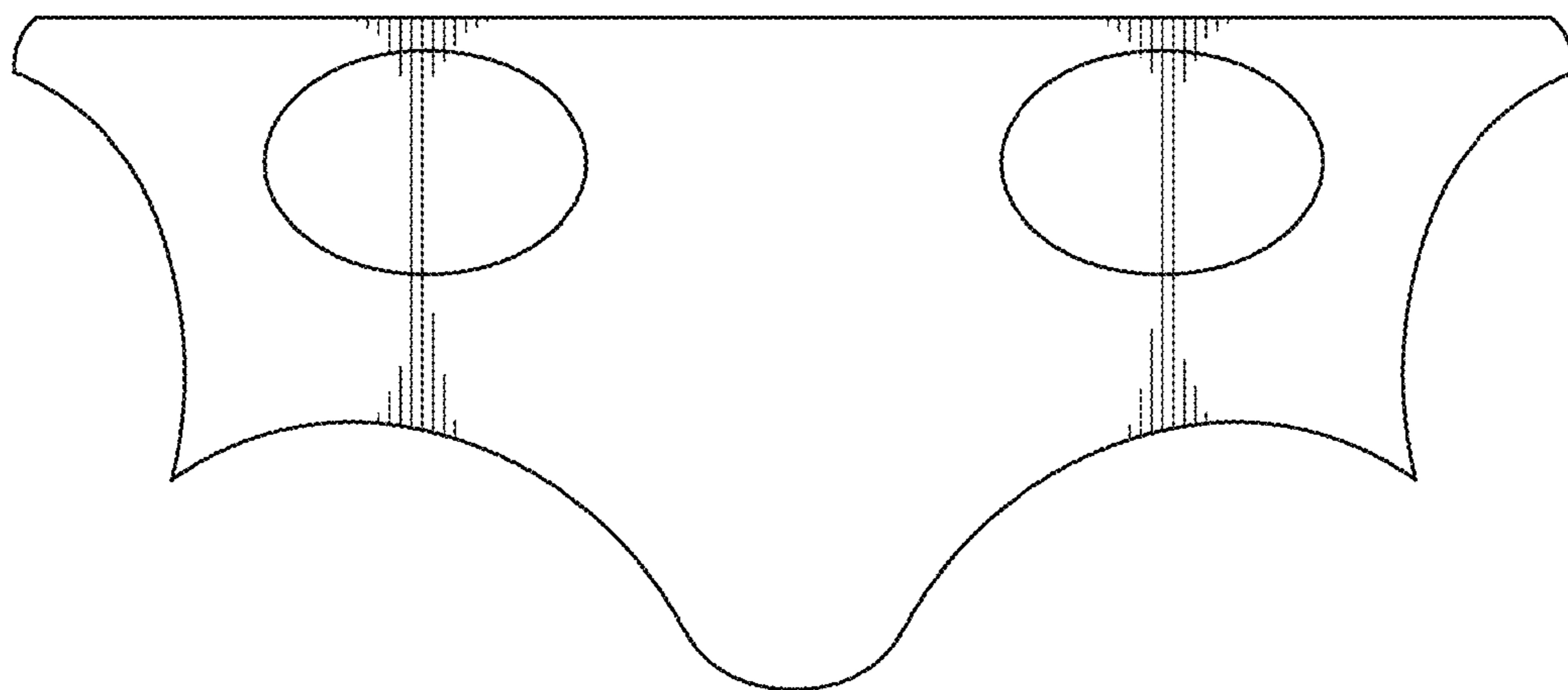


FIG. 2

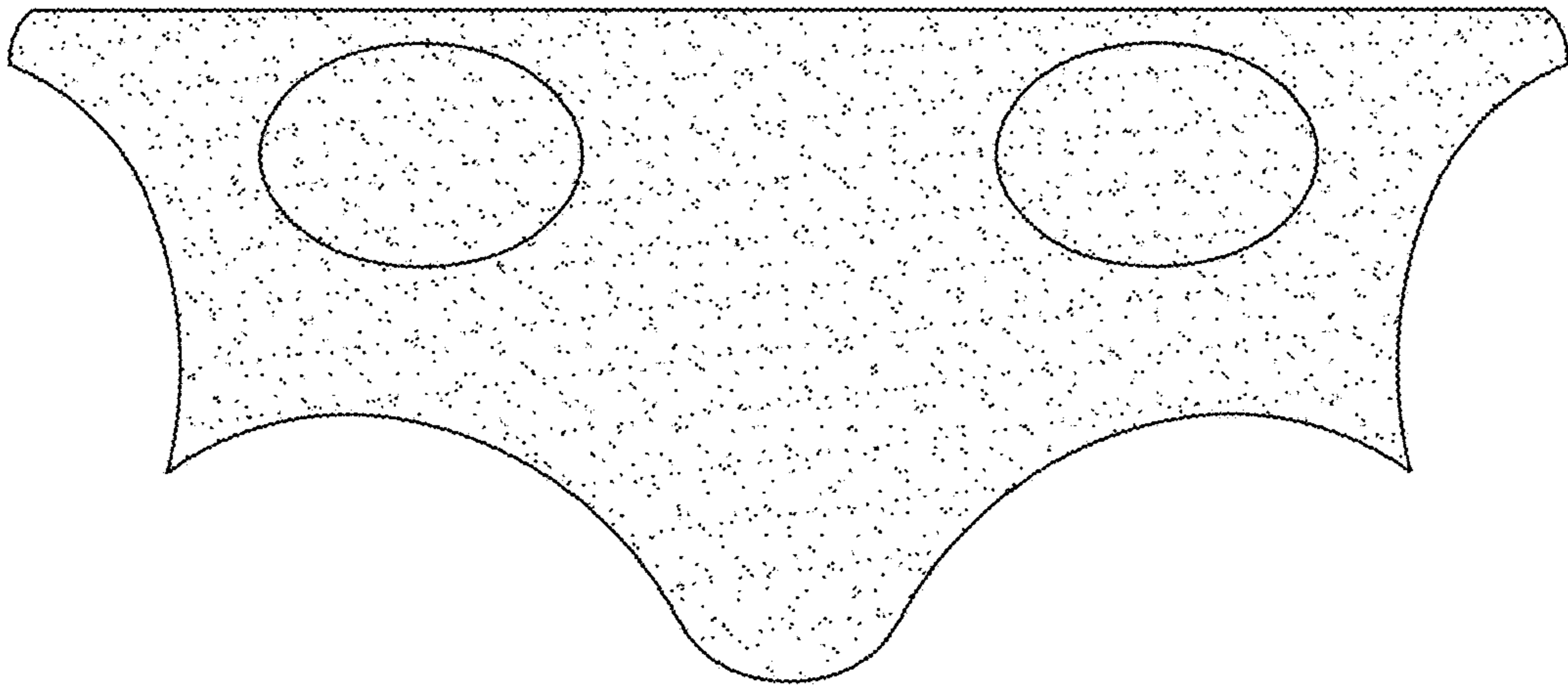


FIG. 3



FIG. 4



FIG. 5



FIG. 6



FIG. 7

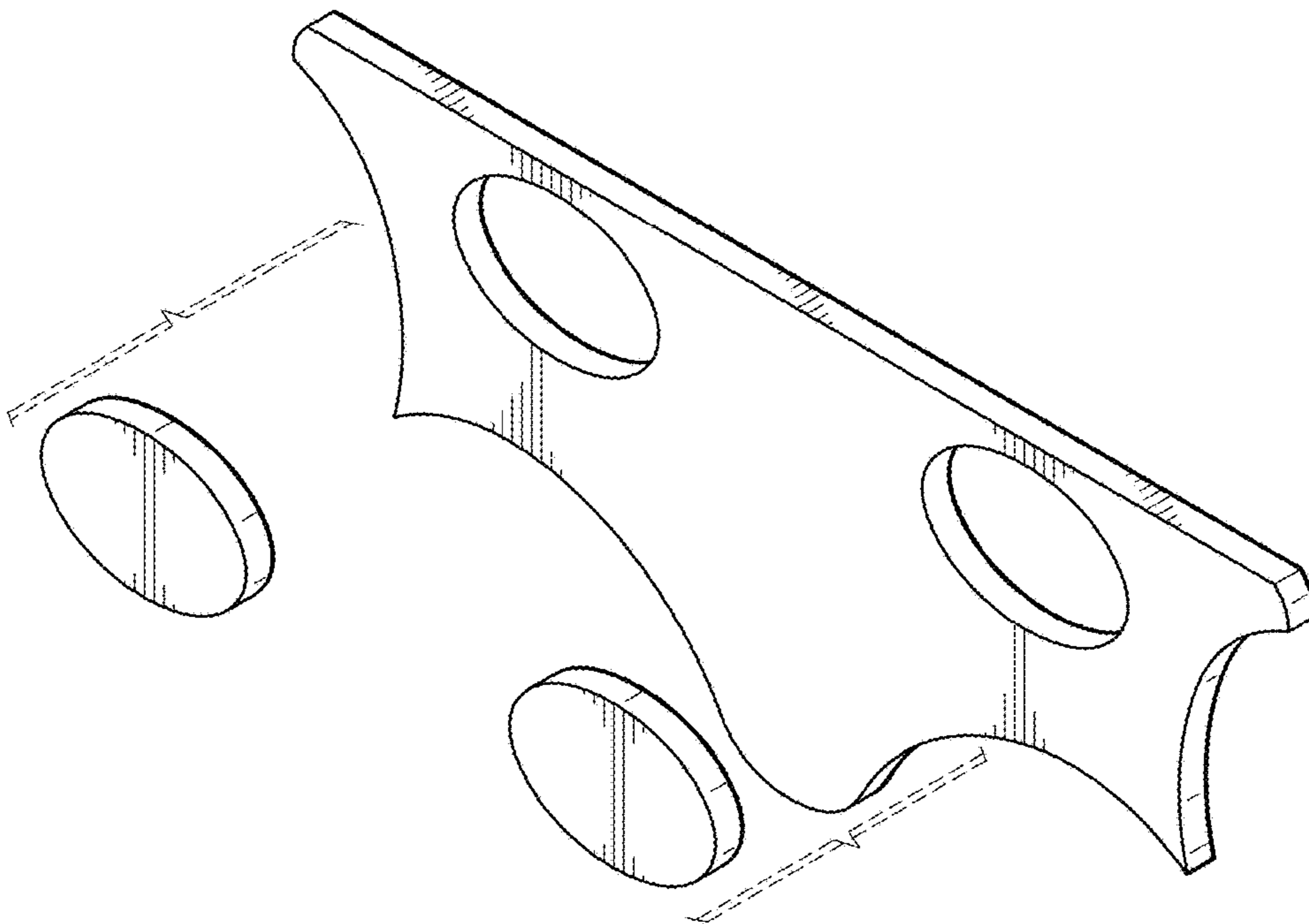


FIG. 8

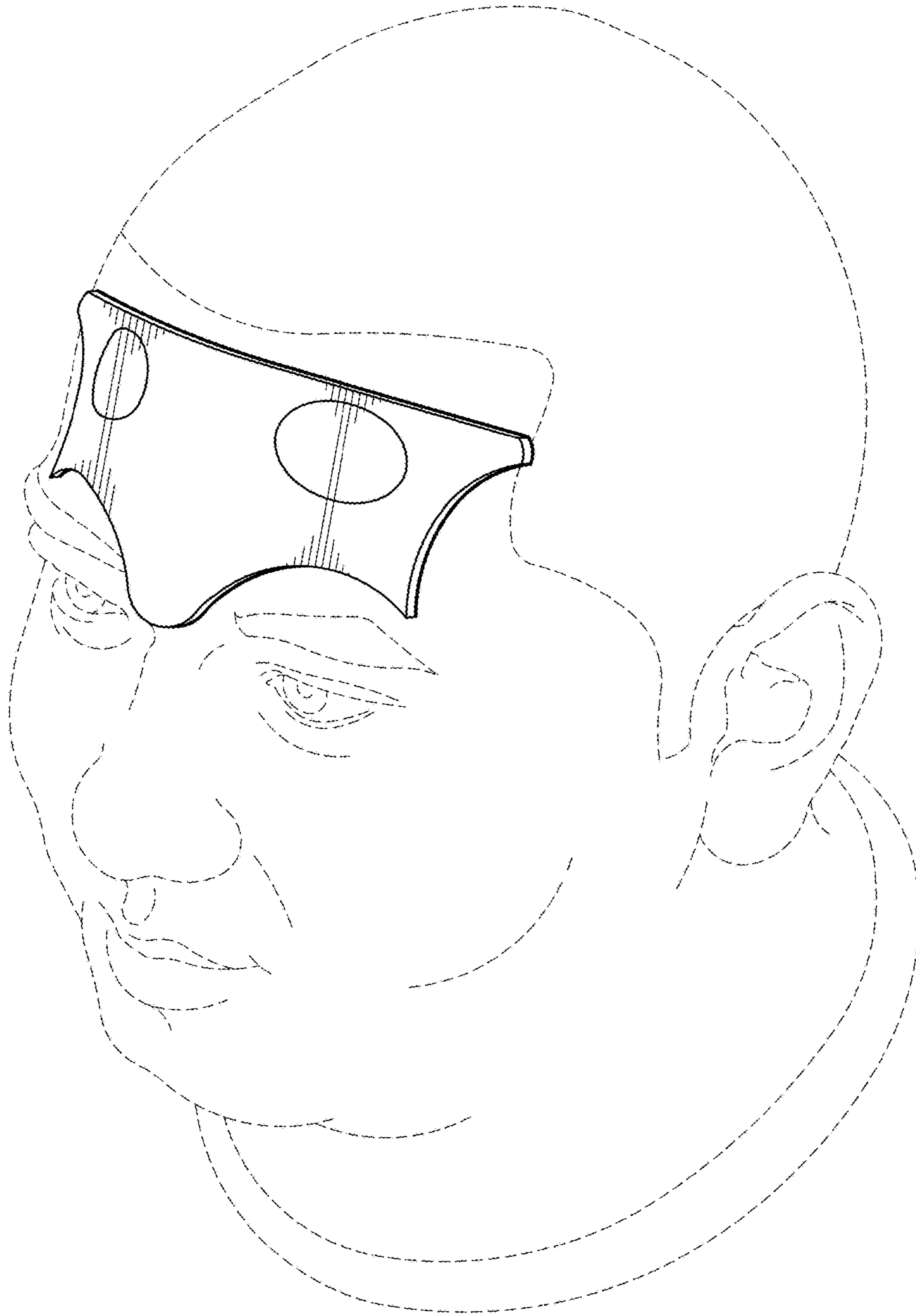


FIG. 9

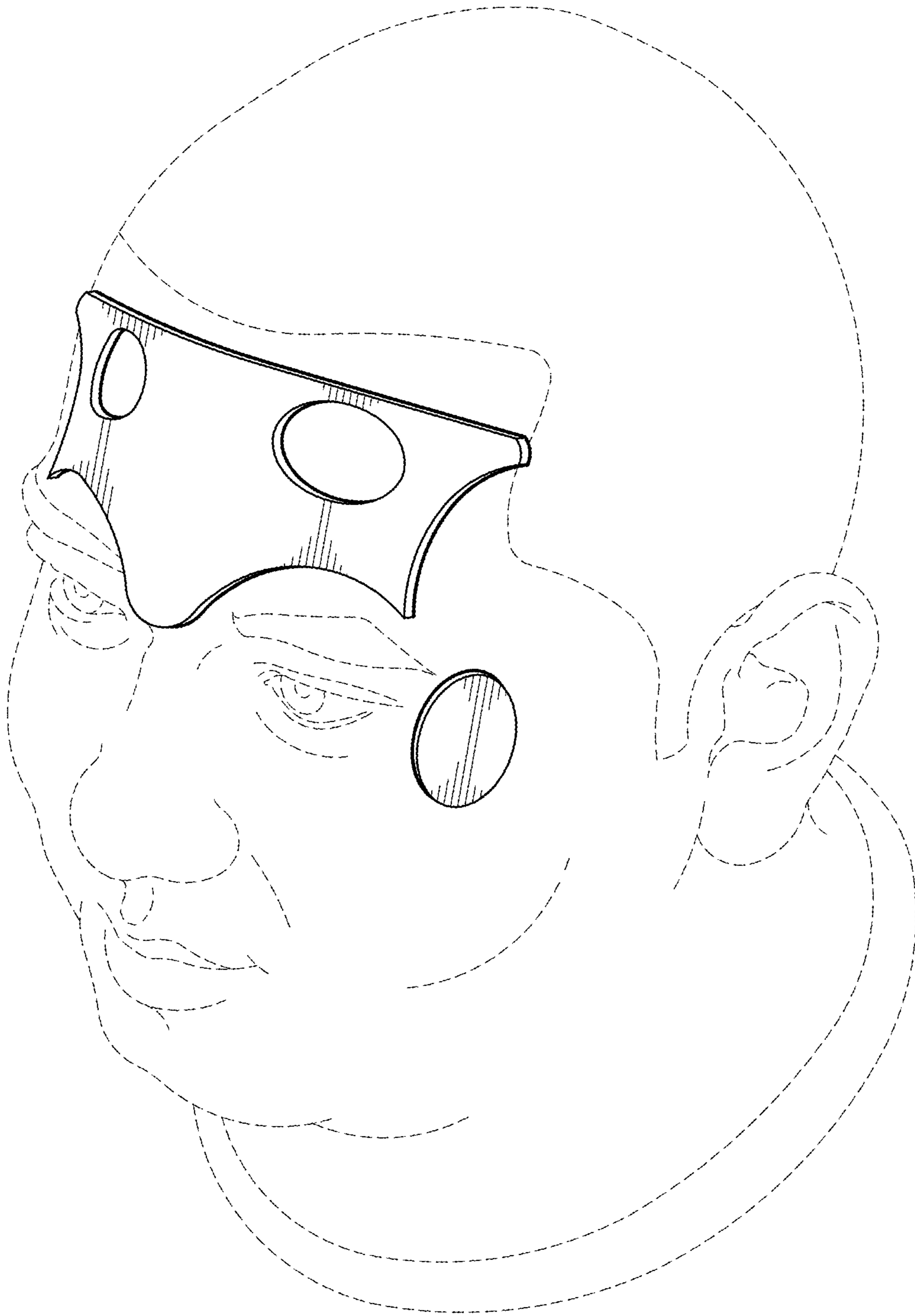


FIG. 10